

EXHIBIT C

IN THE UNITED STATES DISTRICT COURT
FOR THE WESTERN DISTRICT OF TEXAS
WACO DIVISION

DEMARAY LLC,
Plaintiff

W-20-CV-00634-ADA

-v-

INTEL CORPORATION,
Defendant

DEMARAY LLC,
Plaintiff

W-20-CV-00636-ADA

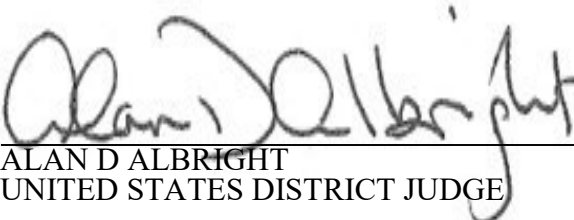
-v-

SAMSUNG ELECTRONICS CO., LTD.
(A KOREAN COMPANY), SAMSUNG
ELECTRONICS AMERICA, INC.,
SAMSUNG SEMICONDUCTOR, INC.,
SAMSUNG AUSTIN
SEMICONDUCTOR, LLC,
Defendants

CLAIM CONSTRUCTION ORDER

The Court held a *Markman* hearing on August 17, 2021. During that hearing, the Court provided its final constructions. The Court now enters those claim constructions.

SIGNED this 17th day of August, 2021.


ALAN D ALBRIGHT
UNITED STATES DISTRICT JUDGE

Term	Plaintiff’s Proposed Construction	Defendants’ Proposed Construction	C C
<p>“Substrate”</p> <p>U.S. Patent Nos. 7,381,657, Claims 1, 2, 7, 11; 7,544,276, Claims 1, 2, 6, 10</p> <p>Proposed by Defendants</p>	<p>Plain and ordinary meaning,</p> <p>or “material that provides the surface on which something is deposited or inscribed, for example a silicon wafer used to manufacture integrated circuits”</p>	<p>“base support structure”</p> <p>or “base support structure that provides the surface on which something is deposited, for example the entirety of a wafer and all layers on that wafer”</p>	<p>Plain-and-which incl limited to an insulato</p>
<p>“A method of depositing a film on an insulating substrate, comprising”</p> <p>U.S. Patent No. 7,381,657, Claim 1</p> <p>Proposed by Defendants</p>	<p>Preamble is not limiting</p>	<p>Preamble is limiting.</p> <p>“insulating substrate” means “insulating [substrate]”</p>	<p>Preamble except for substrate”</p>
<p>“Providing pulsed DC power”</p> <p>U.S. Patent No. 7,381,657, Claims 1, 2, 11</p> <p>Proposed by Defendants</p>	<p>Plain and ordinary meaning,</p> <p>or “pulsed DC power” means “direct current power that oscillates between positive and negative voltages”</p>	<p>“providing DC power in the form of a square wave at a set frequency, reverse time, and amplitude”</p>	<p>“direct cur oscillates negative v</p>
<p>“Pulsed DC power supply”</p> <p>7,544,276 Patent, Claims 1, 6</p> <p>Proposed by Defendants</p>	<p>Plain and ordinary meaning</p> <p>or “supply for providing [pulsed DC power]”</p>	<p>“power supply, which provides DC power in the form of a square wave at a set frequency, reverse time, and amplitude”</p>	<p>“supply fo DC power</p>

Term	Plaintiff's Proposed Construction	Defendants' Proposed Construction	C C
<p>“Narrow band rejection filter”</p> <p>U.S. Patent Nos. 7,381,657, Claims 1, 2, 20; 7,544,276, Claims 1, 6</p> <p>Proposed by Defendants</p>	<p>Plain and ordinary meaning, or “filter which rejects a narrow band of frequencies”</p>	<p>“filter which rejects a narrow band of frequencies (but passes [substantially] all frequencies outside of the narrow band)”</p> <p>or “filter that rejects a narrow band of frequencies centered on one RF bias frequency”</p>	<p>Plain-and-</p>
<p>“Reconditioning the target”</p> <p>U.S. Patent No. 7,381,657, Claim 1</p> <p>Proposed by Defendants</p>	<p>Plain and ordinary meaning, or “cleaning and conditioning the target”</p>	<p>“conditioning the target between depositions”</p>	<p>Plain-and-</p>
<p>(a) “Metallic mode”</p> <p>U.S. Patent No. 7,381,657, Claims 1, 2</p> <p>(b) Poison mode”</p> <p>U.S. Patent No. 7,381,657, Claims 1, 2</p> <p>Proposed by Plaintiff</p>	<p>(a): “mode of operation in which the surface of the target is substantially metallic”</p> <p>(b): “mode of operation in which the rate of the thin film formation on the surface of the target equals or exceeds the rate of sputter removal of the surface of the target”</p>	<p>Plain and ordinary meaning for each</p>	<p>Metallic m ordinary m</p> <p>Poison mo ordinary m</p>

Term	Plaintiff's Proposed Construction	Defendants' Proposed Construction	C C
<p>“the temperature of the substrate substantially constant”</p> <p>U.S. Patent Nos. 7,381,657, Claim 7; 7,544,276, Claim 10</p> <p>Proposed by Defendants</p>	<p>Plain and ordinary meaning, or “substantially constant” means “within about 10°C”</p>	<p>“the substrate temperature to be within about 10 °C of the set temperature”</p>	<p>Plain-and-</p>